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Laser Ablated High T_c Superconducting Thin $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ Films on Substrates Suitable for Microwave Applications

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The development of high temperature superconducting $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ thin films on substrates suitable for microwave applications is of great interest for evaluating their applications for space radar, communication, and sensor systems. Thin films of $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ have been formed on SrTiO_3 , ZrO_2 , MgO , and LaAlO_3 substrates by laser ablation. The wavelength used was 248nm from a KrF excimer laser. During deposition the films were heated to 600° C in a flowing oxygen environment, and required no post annealing. The low substrate temperature during deposition with no post annealing gave films which were smooth, which had their c-axis alligned to the substrates, and which had grains ranging from 0.2 to 0.5 microns in size. The films being c-axis alligned gave excellent surface resistance at 35 GHz which was lower than that of copper at 77 K. At present, LaAlO_3 substrates with a dielectric constant of 22, appears suitable as a substrate for microwave and electronic applications. The films have been characterized by resistance-temperature measurements, scanning electron microscopy, and x-ray diffraction. The highest critical transition temperatures (T_c) are above 89K for films on SrTiO_3 and LaAlO_3 , above 88K for ZrO_2 , and above 86K for MgO . The critical current density (J_c) of the films on SrTiO_3 is above 2×10^6 amperes/cm² at 77K. The T_c and J_c are reported as a function of laser power, composition of the substrate, and temperature of the substrate during deposition.

Resistance versus temperature for a $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ film on LaAlO_3 is shown in fig. 1. Its transition temperature is 89.6 K.

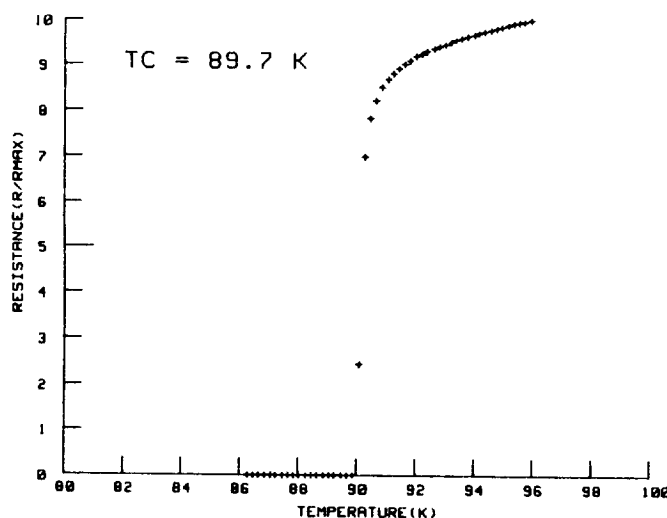


Fig. 1 Laser ablated $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ Film on LaAlO_3 .

Deposition temperature 610°C and oxygen pressure of 170 mtorr.